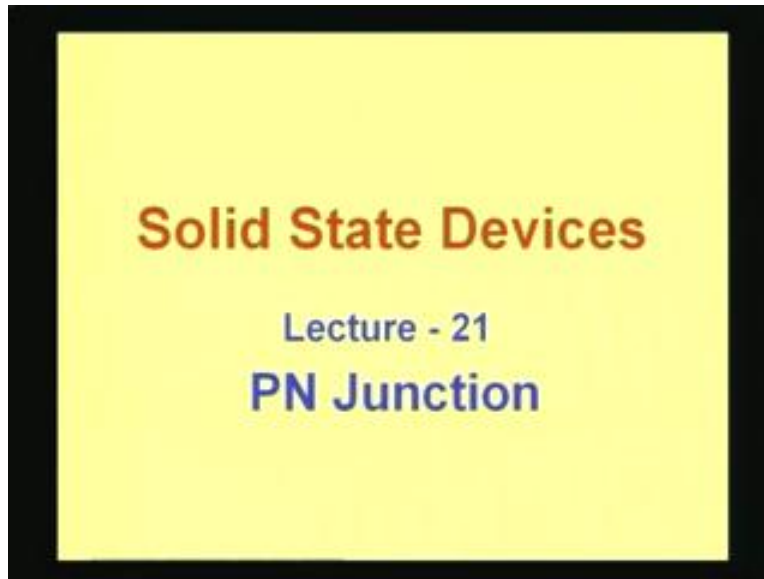


**Solid State Devices**  
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**Lecture - 21**  
**PN Junction (Contd...)**

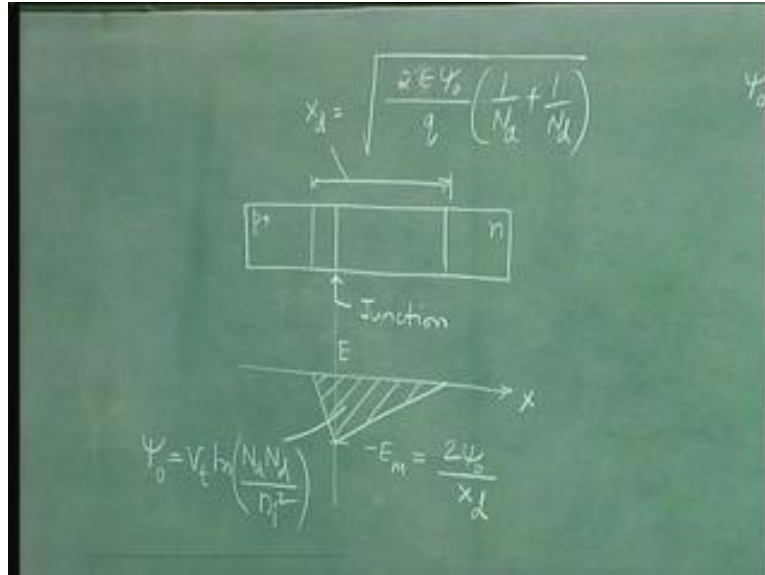
This is the 3rd lecture on the PN junctions and the 21st lecture of this course.

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In the previous lecture we had completed the equilibrium analysis and we had obtained the concentrations of electrons and holes and then the electric field distribution in a space charge layer that is located near the junction. We also showed that the space charge layer can be assumed to be depleted of free carriers. Since  $J_n$  and  $J_p$  the electron and holes current densities are 0 under equilibrium we did not draw the distribution of  $J_n$  and  $J_p$  separately. The result of our analysis can be illustrated using this diagram.

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This is the depletion layer, this is the junction and this is the electric field picture under the depletion approximation. In this lecture we will continue with the equilibrium analysis. To start with what we will do is we will try to estimate the various parameters namely the depletion width, the peak electric field and the built-in potential for a typical situation. So let us look at the slide which gives the details of the solved example that we are going to consider.

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**Solved example**

An abrupt and uniformly doped p-n junction has doping levels of  $N_a = 10^{16} \text{ cm}^{-3}$  and  $N_d = 10^{15} \text{ cm}^{-3}$ . Estimate the following

- (i) depletion width
- (ii) built-in potential.
- (iii) peak electric field
- (iv) average diffusion current densities of electrons and holes, in the depletion layer

You have an abrupt and uniformly doped p-n junction with doping levels of  $10^{16} \text{ cm}^{-3}$  on the p-side and  $10^{15} \text{ cm}^{-3}$  on the n-side, We want

to estimate the depletion width, built-in potential, peak electric field and finally we will also estimate the average diffusion current densities of electrons and holes in the depletion layer. These diffusion current densities will be very useful starting points for the non-equilibrium analysis or the analysis under bias.

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The image shows handwritten calculations on a green chalkboard. On the left, the built-in potential  $\psi_0$  is calculated using the formula  $\psi_0 = V_t \ln\left(\frac{N_a N_d}{n_i^2}\right)$ . This is then simplified to  $V_t \ln\left(\frac{10^{16+15-20}}{1.5^2}\right)$ , then to  $V_t \ln\left(\frac{10^{11}}{1.5^2}\right)$ , then to  $24.5 V_t - 0.026 V$ , and finally to  $0.638 V$ . On the right, the depletion width  $X_d$  is given by the formula  $X_d = \sqrt{\frac{2\epsilon\psi_0}{q}\left(\frac{1}{N_d} + \frac{1}{N_a}\right)}$ .

The built-in potential  $\psi_0$  is equal to  $v_t \ln(N_a N_d \text{ by } n_i \text{ square})$  so we can calculate this as follows at room temperature. So  $t$  is equal to 300 K that is the assumption. So we can write this as  $v_t \ln(10 \text{ to the power } 16 \text{ plus } 15 \text{ minus } 20 \text{ by } 1.5 \text{ square}) \text{ by } n_i \text{ square}$ . Here  $n_i$  is 1.5 into 10 to the power 10 for silicon. In the denominator you get 1.5 square (10 to the power 20). We will shift this power up here so that calculations become easy. It is useful to keep all the powers of 10 together and all the numbers separately as this avoids mistakes in calculation. So this is equal to  $v_t \ln 15 \text{ minus } 20 \text{ minus } 5 \text{ plus } 16 \text{ is equal to } 11$  so 10 to the power 11 by 1.5 square. So you will get the result as 24.5 into  $v_t$  therefore you get about twenty five times thermal voltage built-in potential. Substituting  $v_t$  as 0.26 volts you get the result as 0.638 mV or 0.638 V which is about 0.65 volts which is the built-in potential of a p-n junction with 10 to the power 16 and 10 to the power 15 cm cube doping levels. If the doping levels change and they are more obviously your built-in potential will be more but note that the doping levels come in the logarithm.

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$$V_{bi} = V_t \ln \left( \frac{N_a N_d}{n_i^2} \right)$$

$$V_t \ln \left( \frac{10^{16+15-20}}{1.5^2} \right) = 0.026 V$$

$$24.5 V_t = 0.638 V$$

$$X_d = \sqrt{\frac{2 \epsilon_s \epsilon_0}{q} \left( \frac{1}{N_a} + \frac{1}{N_d} \right)}$$

$$= \sqrt{\frac{2 \times 0.638 \times 1.1 \times 10^{-12} \times 1.6 \times 10^{-19}}{1.6}} \times \sqrt{10^{19} + 10^{15}}$$

$$= 0.97 \times 10^{-4} \text{ cm} = 0.97 \mu\text{m}$$

Unit analysis:  $8.85 \times 10^{-14} \text{ F/cm} \times 10^{-12} \text{ F/cm} = 10^{-26} \text{ F}^2/\text{cm}^2$

Therefore the change is not so significant and you will find at the built-in potential hovers around 0.65 to 0.75 volts for various junctions in silicon. The depletion width  $X_d$  into epsilon the epsilon for silicon is this epsilon is epsilon silicon epsilon<sub>0</sub> the electric constant of silicon is 12 and this epsilon<sub>0</sub> is 8.85 into 10 to the power minus 14 Farad cm. When you multiply these two the result is approximately equal to 10 to the power minus 12 Farad cm. This is the number one can remember as epsilon for silicon. Since we want to collect all the powers of 10 together we will write this power here and also, do not forget to put the units separately. Now  $\psi_0$  is equal to 0.638 volts then comes the  $q(1.6$  into 10 to the power minus 19) and in the denominator this will go up and it will become plus 10 to the power minus 19. Then 1 by  $N_d$  and this should be 1 by  $N_a$  plus 1 by  $N_d$ . So 1 by  $N_a$  will be 10 to the power minus 16 and 1 by  $N_d$  will be 10 to the power minus 15.

Notice that we can take out 10 to the power minus 15 out of the bracket so the result will be 1 here and 0.1 here so it is multiplied by 1.1. In fact it is a common practice when you have one side doping more than ten times the other side you can neglect the heavily doped side level. For example here  $N_a$  is 10 into  $N_d$  so one can neglect this. The error because of that will be only 5%.

Generally it is a practice that if  $N_a$  is more than 10 into  $N_d$  then you neglect  $N_a$ . The heavily doped side doping level is neglected. That is the depletion width  $X_d$  depends on the doping on the lightly doped side predominantly. This is the important conclusion that we get from here. So let us put the units for 1 by  $N_a$  and they will be cm cube. Let us put the unit for  $q$  that is Coulomb. In fact we must put the unit as when you put the number so here Farad into volt is Coulomb, this Coulomb gets cancelled and leads to cm square. If you take the square root you will get cm, so the units are correct because  $X_d$  is the depletion width. The result of this is that we collect these terms; 10 to the power minus 12 plus 19 minus 15 and it results in 10 to the power minus 8 and when you take the square root you will get 10 to the power minus 4 cm. Then we take this number and make

a calculation and you will find, this is 0.97 micrometer because 10 to the power minus 4 cm is 1 micrometer. This is the order of the depletion width. Therefore one can remember the depletion width to be of the order of a micron for a p-n junction doping levels of 10 to the power 16 and 10 to the power 15 on both the sides. If your doping levels are higher clearly your depletion width will be smaller. It is useful to remember values for one particular doping level because then you can find out the values for any other doping level very quickly.

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Handwritten calculations on a green chalkboard:

$$V_0 = V_t \ln \left( \frac{N_a N_d}{n_i^2} \right)$$

$$V_t \ln \left( \frac{10^{16+15-20}}{1.5^2} \right)$$

$$= V_t \ln \left( \frac{10^{11}}{1.5^2} \right)$$

$$= 24.5 (V_t) - 0.026 V$$

$$= 0.638 V$$

$$X_d = \sqrt{\frac{2\epsilon_0 \epsilon_r}{q} \left( \frac{1}{N_a} + \frac{1}{N_d} \right)}$$

$$= \sqrt{\frac{2 \times 0.638 \times 1.17 \times 10^{-12} \times 1.5}{16} \frac{P \times 10^{22}}{94 \times 10^9}}$$

$$= 0.97 \times 10^{-4} \text{ cm}$$

$$= 0.97 \mu\text{m}$$

$$E_m = \frac{2V_0}{X_d} = \frac{2 \times 0.638}{0.97 \times 10^{-4}} \frac{V}{\text{cm}}$$

$$= 13.2 \frac{\text{KV}}{\text{cm}}$$

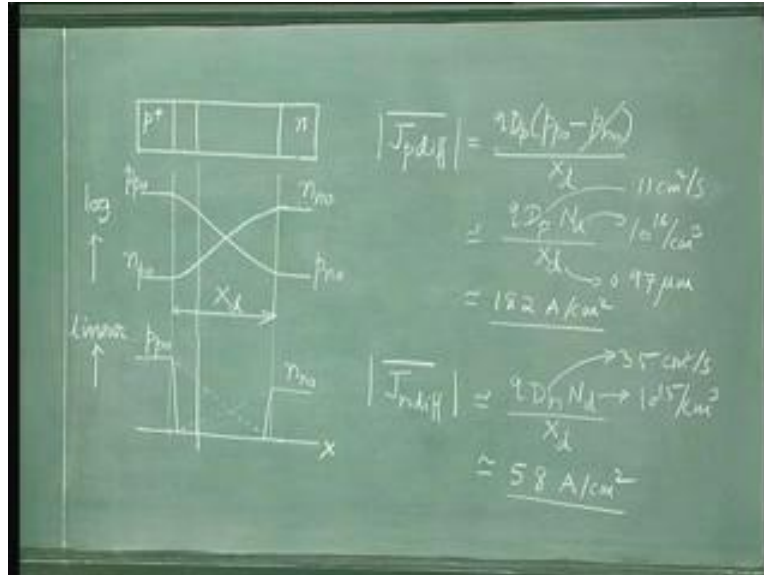
Additional notes on the left side of the board:

$$\epsilon_0 \rightarrow 8.85 \times 10^{-14} \text{ F/cm}$$

$$\approx 10^{-12} \text{ F/cm}$$

Finally the  $E_m$  the peak electric field is 2 into  $\psi_0$  by  $X_d$  is equal to 2 into 0.638 volts by  $X_d$  is 0.97 into 10 to the power minus 4 cm. If you shift this up you will get 10 to the power 4 which means tens of kilo volt and that is why your unit will be kilovolt cm for the peak electric field and the value turns out to be 13.2. Remember, the peak electric field to be the order of 10 to the power 4 volt cm or tens of kilovolts cm is the kind of electric field so it is a very high electric field. I emphasize that this high electric field is not resulting in any current because the current drift is balanced by the current because of diffusion. So that is why there is no current for either electrons or holes under equilibrium conditions.

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Finally we have the average diffusion and diffusion currents for holes and electrons. Let us look at this diagram which gives you the variation in concentrations on a log scale within the depletion layer. From here one can write the average diffusion current as, for example for holes  $J_p$  diffusion we will put a bar here to show that these are average values  $qD_p(P_{p0} \text{ minus } P_{n0})$  by  $X_d$  so  $P_{p0}$  is the hole concentration on this side  $P_{n0}$  is the hole concentration on the other side and the gradient therefore can be written as  $P_{p0} \text{ minus } P_{n0}$  by  $X_d$ . Now here the  $P_{n0}$  is much less than  $P_{p0}$  so you can neglect this. Further  $P_{p0}$  is approximately equal to the doping level  $N_a$ .

We are assuming complete ionization and neglecting thermal generation. So  $q D_n N_d$  by  $X_d$  is the average drift current. You can substitute the various values as  $N_a$  is  $n$  to the power 16 cm cube, this is 0.97 micrometer and this  $D_p$  for 10 to the power 16 cm cube we have to use the mobility versus doping graph or the equation and we will find this is approximately 35 cm square sec, this is for electrons and for holes it is about 11 cm square sec so you substitute everything and this will be about 182 ampere cm square which is a very high current density for diffusion currents. Again this is balanced by the drift current. We have shown that the field is very high so you are getting a high drift current and that is counter balancing this diffusion current.

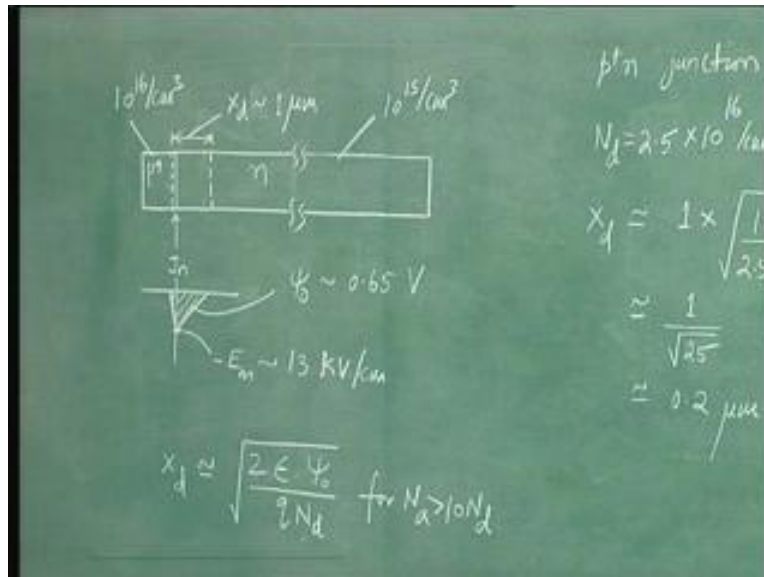
Similarly, one can do for electrons  $N_{n0} \text{ minus } N_{p0}$  is the difference in concentrations over the distance  $X_d$  and that will again reduce to  $q D_n N_d$  by  $X_d$  following the same approach as for holes. So this average current if you substitute the various value is 10 to the power 15 cm cube and  $D_n$  is 35 in cm square for sec for doping level of 10 to the power 15 from the mobility versus doping equation.

Substituting the various values the result is about 58 ampere cm square. This is the average diffusion current of electrons. We must emphasize that this average value should be used with caution. That is because if you see the concentrations on a linear scale

which correctly shows the variation then you find that the electron concentration is dropping rapidly and the hole concentration also dropping rapidly at the depletion edge.

The estimations we have done for  $J_p$  diffusion and  $J_n$  diffusion are based on the slope of these lines and these lines. So these estimates will be way off in fact the diffusion current is much higher. You can see the gradient is more here in these regions whereas in this region you will find the diffusion current values will be much less. That is what we mean by saying that average current which we have calculated should be used with caution. They are only very crude estimates to get a feel for the fact that the equilibrium situation in this case implies very high drift and diffusion currents exactly in balance within the depletion layer. Now let us summarize some of the quantitative values from this example and carry out to the rest of the course.

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For your p to the power plus n junctions the p-side is of the order of microns whereas the n-side is of the order of several tens of microns. In fact we saw this was 1 micron and this side was 100 micron in our real device structure. As we have said we will be assuming that these two regions are sufficiently longer than their diffusion lengths.

Now, the depletion width here is of the order of 1 micron for 10 to the power 16 cm cube and 10 to the power 15 cm cube doping levels. So, if we remember the values for this particular doping level then we can make calculations for other doping levels very easily. This is the electric field picture and the area under this is a built-in potential that is of the order of 0.65 volts for the doping levels under consideration and the peak electric field is tens of kilo volt cm. This is what one must remember.

This is a diagram which is not exactly to scale but it is somewhat to scale in the sense that here you can see the depletion width and the width of the p-region are almost of the same



order whereas this n-region width is very long compared to the depletion width. This is the practical situation in p plus n junction that you encounter.

Finally the depletion width formula for p to the power plus n junction is where  $N_a$  is more than  $10^{16}$  into  $N_d$  again this is the kind of situation we will encounter in practice. It is very simple as it is  $2$  into  $\epsilon_0$  to the power star  $\psi_{i0}$  by  $q$  into  $N_d$ . This formula is very easy to remember because the  $q$  always goes with the doping because this is the ionized impurity charge and this is the space charge in the depletion layer. And then you know that the depletion width will be more if the built-in potential is more. This is very easily understood based on our knowledge of Physics. We also know that the depletion width will be less if the doping is more. So the doping is in the denominator and the built-in potential is in the numerator. The  $q$  always goes with the charge.

Now, to get the correct dimensions you can see that the dielectric constant should appear along with the square. This factor of  $2$  comes because the electric field is triangular in shape and the area under the electric field consists of half of depletion width into the peak electric field so that half is coming here on this side as a  $2$  factor and then you have a square root. Now let us see that if you know these values how you can make a quick estimate for other conditions. One example is shown here.

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$p+n$  junction  
 $N_d = 2.5 \times 10^{16} / \text{cm}^3$   
 $x_d = 1 \times \sqrt{\frac{10^{15}}{2.5 \times 10^{16}}} \text{ cm}$   
 $\approx \frac{1}{\sqrt{25}}$   
 $\approx 0.2 \text{ cm}$

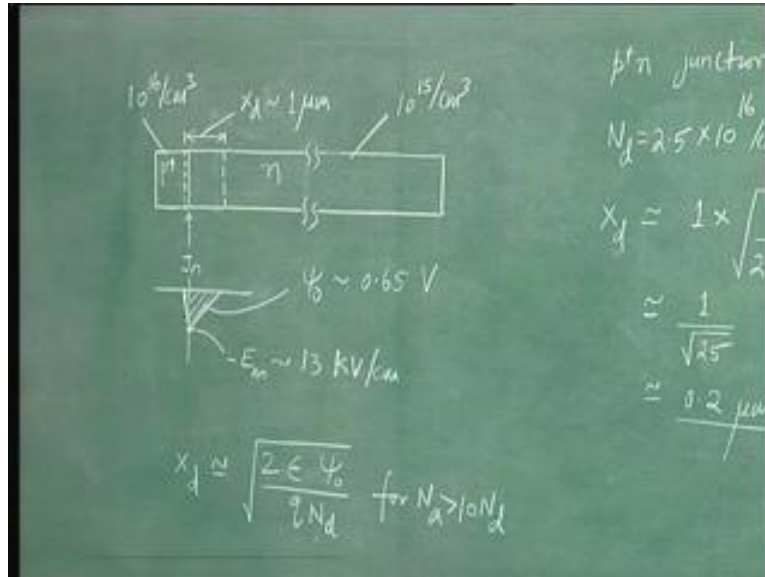
Supposing you have an example of p to the power plus n junction with n-side doping as  $2.5$  into  $10$  to the power  $16$  then how do we quickly estimate the depletion width without doing detailed calculations?

Now we remember that for  $10$  to the power  $15$  cm cube it is  $1$  micron and we know that the depletion width is inversely proportional to the square root of doping and the depletion will be less if the doping is more. For this case the depletion width has to be less than  $1$  micron case. Therefore in the square root you put  $10$  to the power  $15$  in the



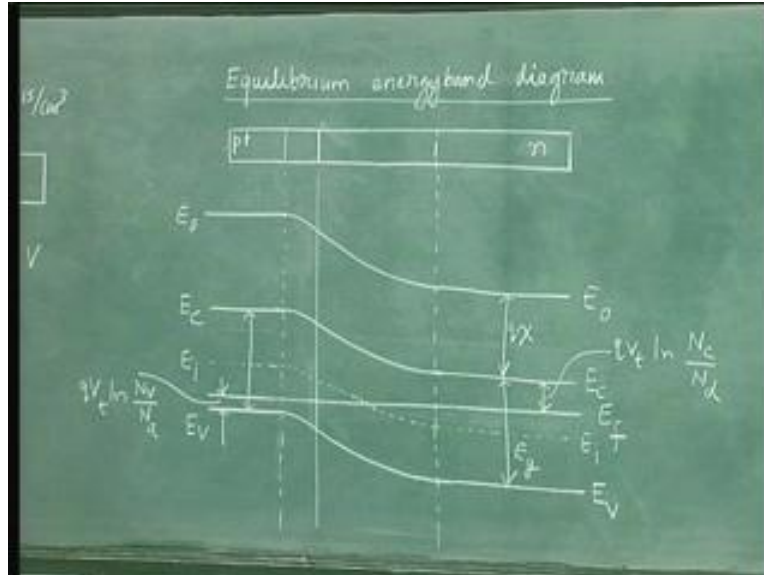
numerator and this value in the denominator and you end up with 1 by square root of 25 which is about 0.2 micrometer. So, one can make this kind of a calculation by inspection. That is the advantage of remembering this approximate formula for a p plus n junction.

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You can always translate this formula for n to the power plus p junction. For example, if  $N_d$  is more than 10 into  $N_a$  then this  $N_d$  here will be replaced by  $N_a$ . Always the depletion width depends on the lightly doped region. So that is the end of the solved example. So far in our analysis we have not used the energy band diagram. From the five basic equations we have derived the information about n, p,  $J_n$ ,  $J_p$  and e. We have estimated the built-in voltage, the depletion width, the peak electric field and so on. Now we would like to look at the energy band diagram under equilibrium for a p-n junction. Then we will see what advantage the energy band diagram offers and what new information does it give.

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To draw the energy band diagram what is the starting point. The starting point is a constant  $E_f$  as a function of  $x$ . You would recall that in an earlier lecture when we were discussing the procedure for device analysis we considered the equilibrium situation and then we showed that if the transport equations are written in terms of the Quasi Fermi-level gradients then  $J_n$  is equal to 0 and  $J_p$  is equal to 0 in equilibrium translated to the gradient of the Quasi Fermi-levels is equal to 0 which means that the Quasi Fermi-levels are constant with distance and since the electrons and the hole Quasi Fermi-levels are same in equilibrium it amounts to saying that the Fermi-level is constant with distance. So this is the starting point for drawing the energy band diagram. Once this is done the next step is to draw the energy band diagrams in the neutral p and n regions. So using the doping levels we can sketch the  $E_c$  and  $E_v$ . So on the n-side for example the  $E_c$  will be close to  $E_f$  but since this is a neutral region and is uniformly doped the  $E_c$  will be flat.

You can look at the  $E_v$  below this at a distance of energy gap. We can repeat a similar thing on the p-side since the p-side doping level is more than n-side doping level.  $E_c$  minus  $E_f$  will be more than  $E_f$  minus  $E_v$  so  $E_v$  will be closer to  $E_f$  than  $E_c$  to  $E_f$  on the n-side. This is your  $E_v$  and then we can place the  $E_c$  at a distance of 1 energy gap so this is  $E_c$ .

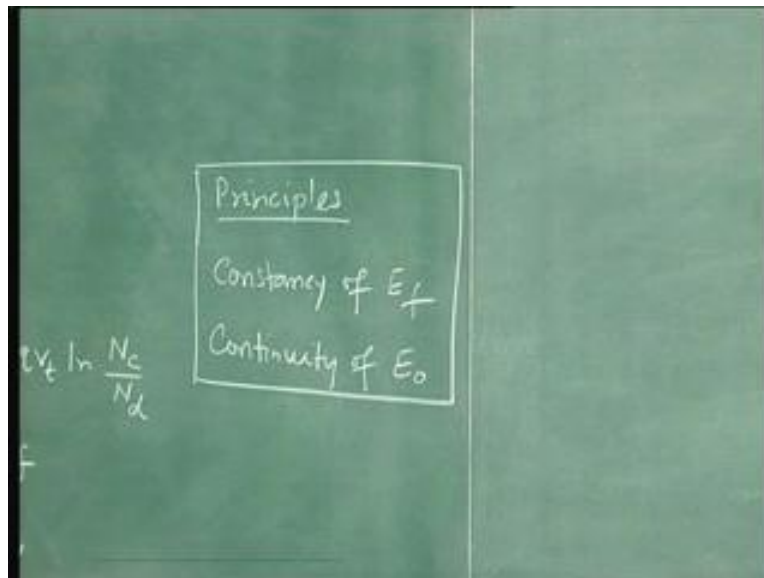
Now we need to join this end of  $E_c$  to this end of  $E_c$  and we need to join this end of  $E_v$  to this end of  $E_v$ . While joining this we must remember that the  $E_c$  and  $E_v$  must be continuous even though they vary with distance. This is because any gradient of  $E_c$  represents the electric field. This point was discussed in lecture on Carrier Transport that the gradient of the band edges  $E_c$  and  $E_v$  represents the electric field. Now, you cannot have infinite electric field anywhere so  $E_c$  and  $E_v$  variations cannot have any discontinuities. So you must draw continuous variations so that is the  $E_c$  and  $E_v$  variations in the depletion layer. The next is we can draw  $E_i$  that is the intrinsic level in between  $E_c$  and  $E_v$ .

The intrinsic point is somewhere here where  $E_i$  crosses  $E_f$ . It lies on the lighter doped side. Now we can also draw the vacuum level  $E_0$  at a distance electron affinity from  $E_c$ . Let us start from this end so this is  $E_0$  and in the same distance you should have  $E_0$  and now we join them by a continuous line that is  $E_0$  where this distance is electron affinity and this distance  $E_g$  energy gap. This electron affinity is in volts so normally you multiply by  $q$  to indicate that it is energy and this is energy gap. Now this  $E_c$  minus  $E_f$  depends on a doping level. So this  $E_c$  minus  $E_f$  is nothing but  $q$  into  $v_t \ln N_c$  by  $N_d$ . On the other hand this  $E_f$  minus  $E_v$  is nothing but  $v_t \ln N_v$  by  $N_a$  a multiplying factor of  $q$  because it is energy. So this energy band diagram of the p-n junction under equilibrium.

Now this has been sketched based on two principles; one is constancy of  $E_f$  and second is the continuity of the band edges i.e.  $E_c$   $E_v$  and  $E_0$ . In this particular case since we are considering a homo junction i.e. this side and the other side p and n sides both are made of the same material  $E_0$   $E_c$  and  $E_v$  all three were discontinuous and in fact  $E_0$  was not necessary while drawing the energy band diagram of  $E_c$   $E_v$  and  $E_f$  so  $E_0$  was drawn at the end.

However, in the case of hetero junctions the picture is somewhat different because when the materials are different on the p and n side your energy gaps are not the same on p and n sides and therefore if you look at this diagram if this energy gap is not the same as this energy gap then obviously somewhere there will be a discontinuity either in  $E_c$  or in  $E_v$  or in both. Now that being the case it is important to note that in such situations it is the  $E_0$  which should be maintained continuous because  $E_0$  represents the energy corresponding to an electron which is just outside the crystal.

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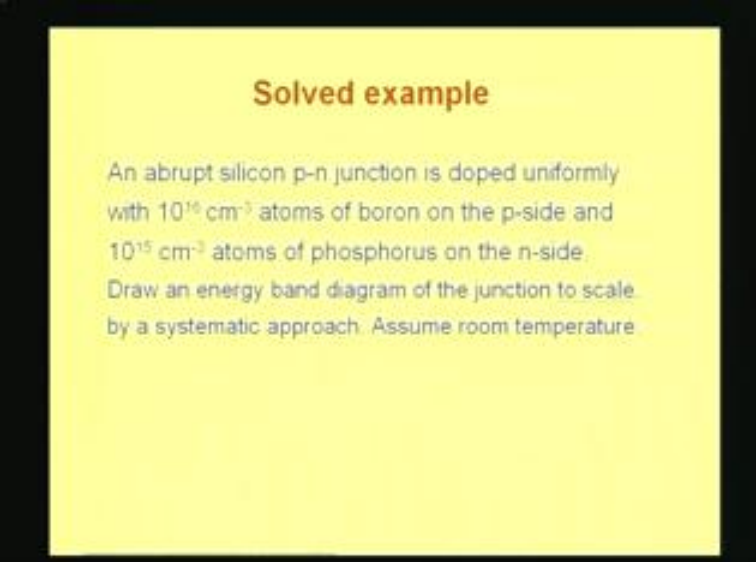


So electron here is the p-n junction. Now if you move the electron along this junction touching this junction from outside it is obvious that this electron should not encounter any infinite electric field here as that will be non physical. Since the gradient of  $E_0$

represents the electric field at this location here therefore the  $E_0$  should be a continuous line because any discontinuity in  $E_0$  would mean an infinite electric field for this electron wherever the  $E_0$  is discontinuous and that is not possible. That is why one states the two conditions for drawing energy band diagram in general, under equilibrium conditions and it means  $E_f$  should be constant and  $E_0$  should be continuous.

The fact that  $E_c$  and  $E_v$  are continuous in a homo junction follows directly from the continuity of  $E_0$  because  $E_c$  should be drawn here where the electron affinity is below the  $E_0$  so  $E_c$  is parallel to  $E_0$ . And since  $E_0$  is continuous and electron affinity is the same throughout then  $E_c$  which is parallel to  $E_0$  should also be continuous and  $E_v$  parallel to  $E_c$  should also be continuous because energy gaps are also the same. We can summarize this by writing the two principles: Constancy of  $E_f$  and continuity of  $E_0$ . They are the principles for drawing energy band diagram. Now we will work out an example to give you a feel for the values of some of the parameters on the energy band diagram and also how an energy band diagram can be drawn for a given condition.

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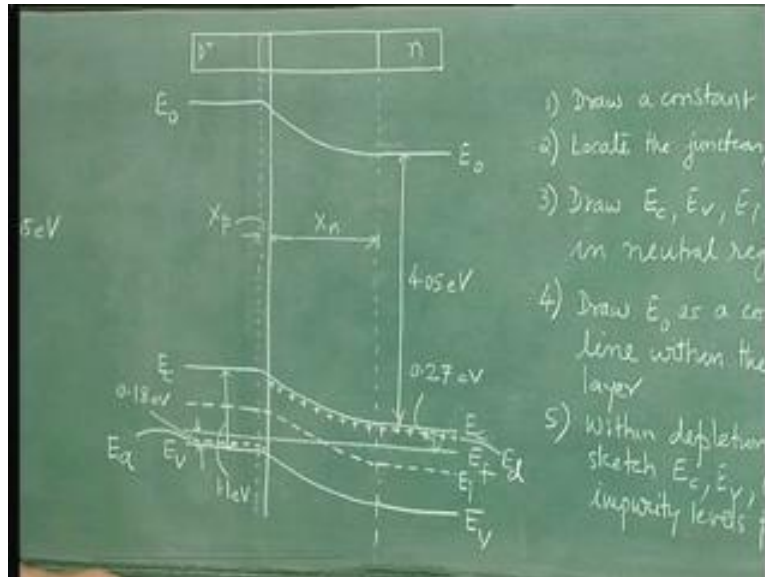


**Solved example**

An abrupt silicon p-n junction is doped uniformly with  $10^{16} \text{ cm}^{-3}$  atoms of boron on the p-side and  $10^{15} \text{ cm}^{-3}$  atoms of phosphorus on the n-side. Draw an energy band diagram of the junction to scale by a systematic approach. Assume room temperature

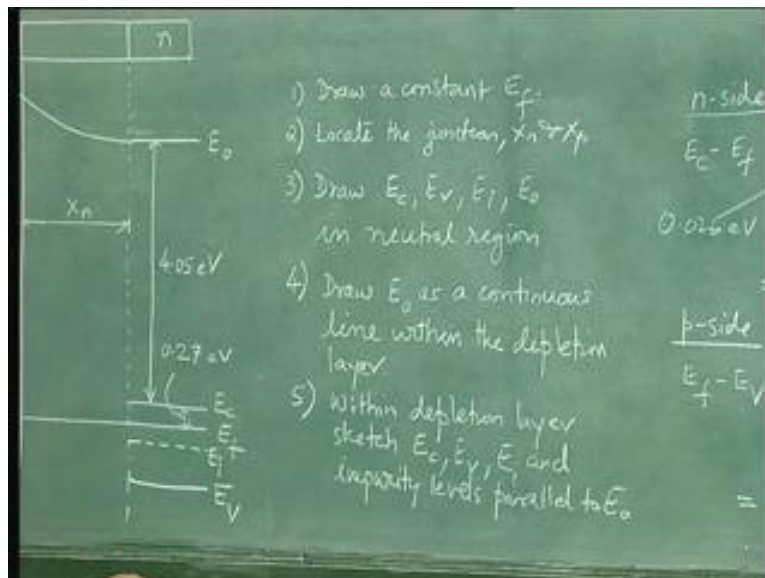
An abrupt silicon p-n junction is doped uniformly with  $10^{16} \text{ cm}^{-3}$  atoms of boron on the p-side and  $10^{15} \text{ cm}^{-3}$  atoms of phosphorous on the n-side. Draw an energy band diagram of the junction to scale by a systematic approach. Assume room temperature. Note that the phrase to scale has been underlined so various parameters should be drawn to scale to get a correct picture.

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The first step in the drawing of energy band diagram is a constant  $E_f$ , so draw a constant  $E_f$ . The second step is to locate the junction. Here the junction has been located on this constant  $E_f$  line. And then after locating the junction we should locate the depletion edges. In this case it is the depletion edge on the p-side which is located at a distance of  $X_p$ . Before drawing the energy band diagram the calculations of the depletion width, built-in potential etc should be completed. So  $X_p$  is on this side and  $X_n$  on the other side so this is  $X_n$ .

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Locate the junction  $X_n$  and  $X_p$ . So  $X_n$  and  $X_p$  represent the depletion edges. After doing that draw the diagram in the neutral regions p plus and n regions. So, the third step is to draw  $E_c$   $E_v$   $E_i$  and  $E_0$  in neutral region. So to do that we must know where  $E_c$  is on the n-side, this can be done as follows.

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locate  $E_f$   
midway,  $X_n$  &  $X_p$   
 $v, E_f, E_0$   
n regions

n-side  
 $E_c - E_f = (kT) \ln \frac{N_c}{N_d}$   
 $0.026 \text{ eV} \quad 2.8 \times 10^{19} / \text{cm}^3 \quad 10^{15} / \text{cm}^3$   
 $= 0.27 \text{ eV}$

p-side  
 $E_f - E_v = (kT) \ln \frac{N_v}{N_a}$   
 $10^{19} / \text{cm}^3 \quad 10^{16} / \text{cm}^3$   
 $= 0.18 \text{ eV}$

You can use the formula  $E_c$  minus  $E_f$  on the n-side is equal to  $KT \ln N_c$  by  $N_d$ . We are assuming complete ionization and neglecting thermal generation so the majority carrier concentration is equal to the doping. Now you substitute the values, for silicon this is 10 to the power 19 into 2.8 cm cube and this is 10 to the power 15 cm cube and  $KT$  at room temperature is 0.026 electron volts. The result is 0.27 electron volts. So we locate  $E_c$  here and the 0.27 electron volts is the difference. If this is 0.27 we must locate the  $E_v$  at one energy gap below so energy gap is 1.1 that is almost four times this. Since we want to draw it to scale we must choose four times this and somewhere here is your  $E_v$  and  $E_i$  is about halfway and it is here, this is  $E_i$ .

Now we should complete a similar exercise on the p-side. So, for p-side you have  $E_f$  minus  $E_v$  is equal to  $KT \ln N_v$  by  $N_a$ . When you substitute the value of  $N_v$  which is 10 to the power 19 cm cube in silicon and  $N_a$  is 10 to the power 16 cm cube and so the result is at room temperature this is 0.18 electron volts. Since we want to draw it to scale notice that 0.18 is 2 by 3 of 0.27 so it is 2 by 3 of this distance you must locate the  $E_v$  here so this is  $E_v$ . And now we should locate the  $E_i$  and  $E_c$ ,  $E_i$  and this is half of energy gap about that distance and then this is  $E_c$ . So this difference is 0.18 electron volts and this difference is 1.1 electron volts energy gap. We should also locate  $E_0$  so  $E_0$  minus  $E_c$  is electron affinity. The electron affinity  $\chi$  into  $q$  is 4.05 electron volts for silicon so this distance is 1.1 and 4.05 would be little less than times this distance. So we must locate four times this distance here and somewhere here is your  $E_0$  and this difference is 4.05 electron volts. We do the same thing here, this is 1, this is 2 and this is about  $2\frac{1}{2}$  so 1 then



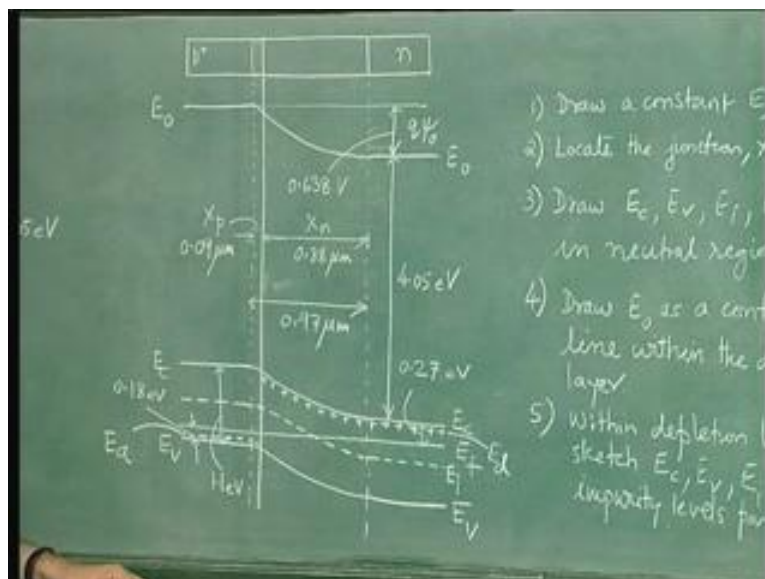
2 and  $2\frac{1}{2}$  is somewhere here i.e.  $E_0$ . So on this side also the difference is 4.05 electron volts.

The next step is to complete the band diagram in the depletion layer. So the fourth step is to draw  $E_0$  as a continuous line with the depletion layer. So you can draw a line like this, now what is the shape of this line?

This line indicates the potential within the device. We have already sketched the potential as the function of  $x$  since the electric field is linear the potential is parabolic so you have one parabola here and another parabola here. They are the two parabolas, so this follows exactly the shape of the potential expect that the potential which you plot for a positive charge where as this energy band diagram is for negative charge, that is the difference so having drawn  $E_0$  you can draw  $E_c$ ,  $E_v$  and  $E_i$  as parallel to  $E_0$ . Within the depletion layer sketch  $E_c$ ,  $E_v$ ,  $E_i$  and impurity levels parallel to  $E_0$ .

Let us do that exercise, so parallel to  $E_0$  we sketch  $E_c$  then sketch  $E_v$  and  $E_i$  and also the impurity levels. Where will the impurity levels be? On the n-side the donor level is close to  $E_c$  but at a distance of 0.05 electron volts. If you compare 0.05 electron volts which is the ionization energy of phosphorus with 0.27 is little more than 5 into 0.05 which means that 1 by 5 of this distance between  $E_c$  and  $E_i$  is the impurity level. So approximately we are locating here so this is the donor level. In the entire region the donor level is very close to the conduction band edge so this is  $E_d$ . similarly one can draw  $E_a$  on this side so  $E_a$  is also at 0.05 electron volts from the valance band edge,  $E_a$  is the acceptor level. And notice the acceptor level has to be drawn parallel to  $E_v$  so donor level is also going to bend like the conduction band edge and other levels like  $E_i$  and  $E_d$ . So with this the energy band diagram is complete. This is how energy band diagram will look like when drawn to scale for a silicon p-n junction.

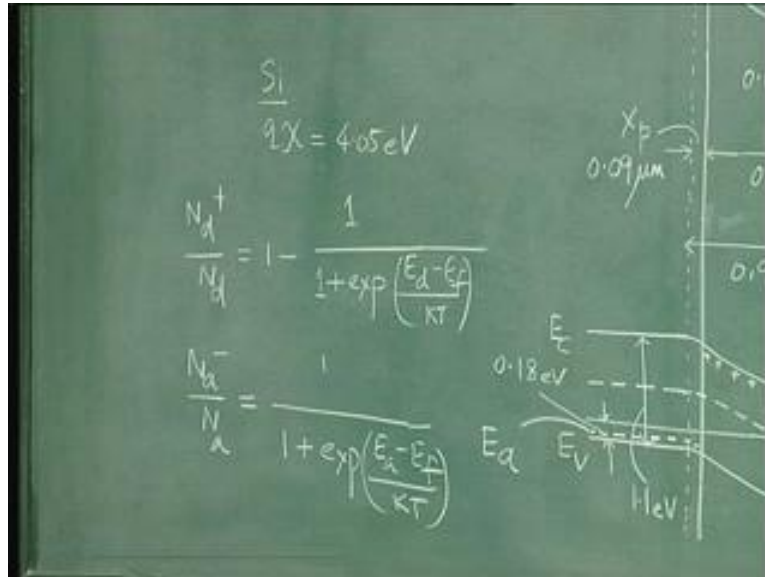
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Now let us look at the some of the advantages of this diagram. What information does it give that we have not obtained from our analysis based on the five basic equations where we drew  $n$ ,  $p$ ,  $J_n$ ,  $J_p$  and  $e$  as a function of  $x$ .

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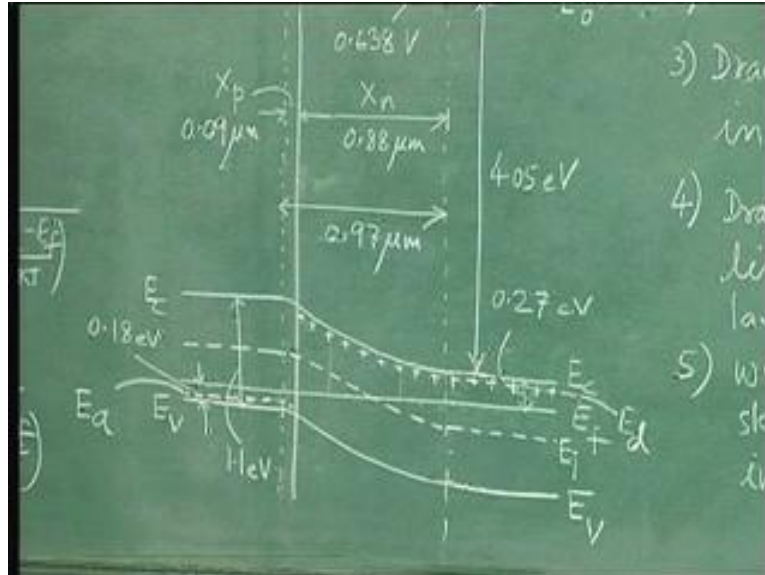


First thing here is the built-in potential is the difference between the  $E_c$  on the two sides or it could be  $E_v$  on the two sides or  $E_i$  on the two sides or it could also be  $E_0$  so this difference is a built-in potential which is 0.638 volts. We have already calculated this value, what about this distance  $X_n$  and  $X_p$ ? This  $X_n$  plus  $X_p$  total distance is 0.97 microns as we have already calculated this.

Now, if doping is ten times on the p-side as compared to n-side you will end up getting a value of  $X_n$  as 0.88 micrometer and you get  $X_p$  to be 0.09 micrometer. Coming back to our discussion on what advantage does the energy band diagram offer, notice that the donor level is varying with distance here. It means that the extent of ionization is changing with distance within the depletion layer because the difference between  $E_d$  and  $E_f$  is what shows the extent of ionization. You know that  $N_d$  plus by  $N_d$  is equal to 1 minus 1 by 1 plus exp of  $E_d$  minus  $E_f$  by  $KT$ . Here you have to multiply by degenerating factor but we are ignoring this degenerating factor in our course as we decided in the beginning. This is the equation that we have written down in one of our earlier lecture for ionized impurity concentration.

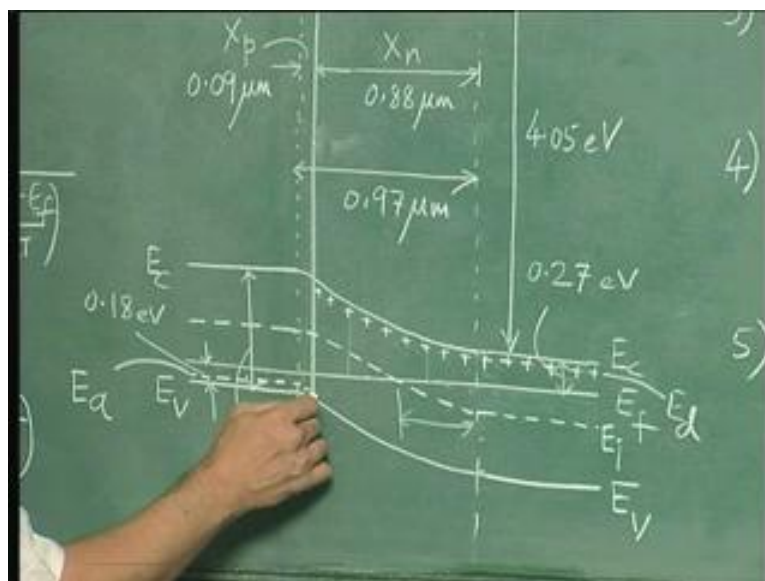
Similarly one can write the expression for  $N_a$  to the power minus by  $N_a$  and this is nothing but 1 by 1 plus exp of  $E_a$  minus  $E_f$  minus  $E_f$  by  $KT$ . So the difference  $E_d$  minus  $E_f$  decides the extent of ionization and the difference  $E_a$  minus  $E_f$  decides the extent of ionization for boron. Since  $E_d$  minus  $E_f$  is changing with distance it means that the extent of ionization is changing. In our problem the extent of ionization is almost complete. This is not really giving any significant information because already the extent of ionization is complete. And if it changes a little bit it does not make any difference.

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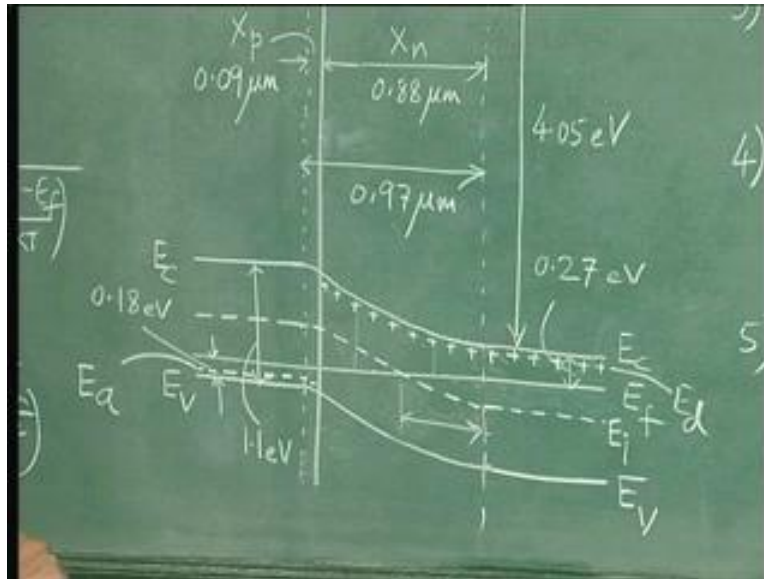
But you will note that if the doping level is heavy and if this Fermi-level moves close to the donor level then the extent of ionization changed shown by this difference  $E_f$  and  $E_d$  will be significant and your space charge picture will be therefore affected. In other words, in the space charge region your space charge concentration will not be exactly  $q$  into  $N_d$  but it will be  $q$  into  $N_d$ . Let me show this with an example, Apart from the shallow donor level which is present there let us say there was a deep level also called as the donor level, and the deep donor level is  $E_i$  the intrinsic level itself then what would happen? Look at the diagram.

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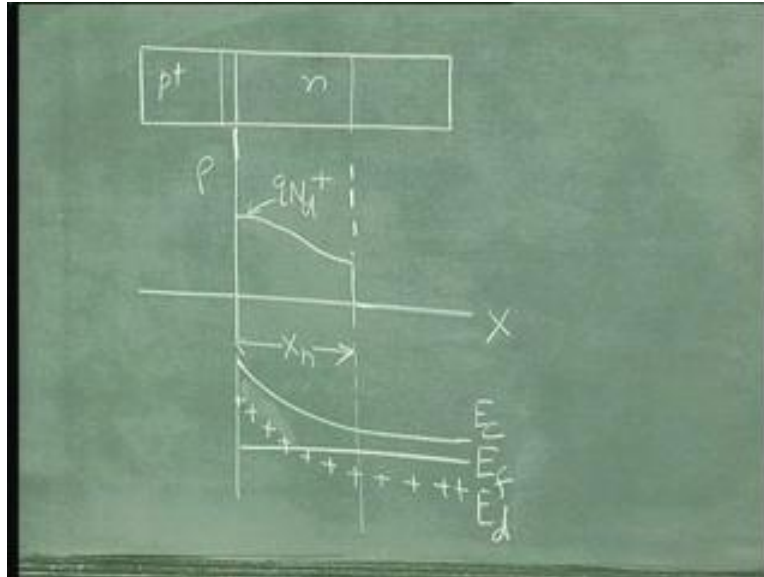
So if you have a donor level along  $E_i$  then you can see that in this portion of a depletion layer the deep donor level is below  $E_f$ . On the other hand, in the remaining portion of the depletion layer on the n-side, this donor level would be above  $E_f$ . Since the levels below  $E_f$  are all occupied a donor level below  $E_f$  means an occupied donor level which also means unionized donor impurity.

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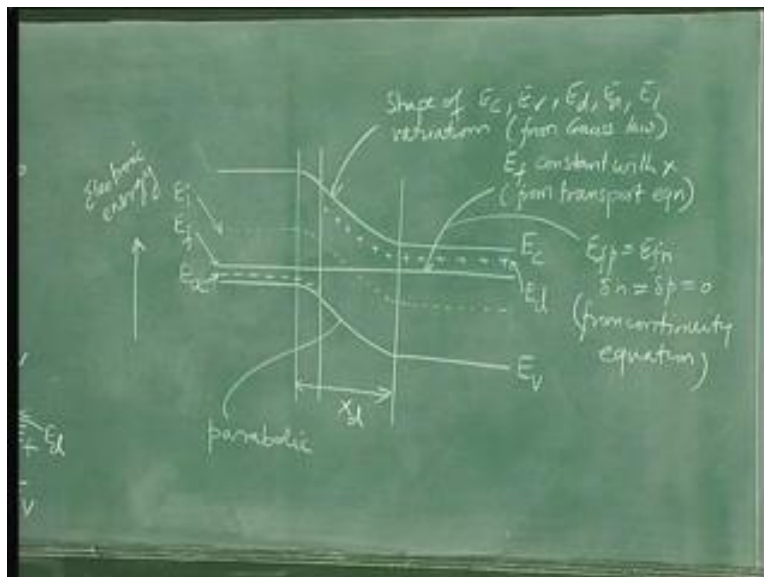
So in this region you will have partial ionization. In fact ionization will be very poor. Gradually the ionization will improve as you move and will become very good near the junction. So from partial ionization to complete ionization the state of ionization of impurity is changing within the depletion layer. Therefore your space charge picture also will be affected. Let us draw this space charge picture for an impurity that is crossing the Fermi-level.

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We are assuming a donor impurity which crosses the Fermi-level and the picture being as shown in the band diagram here. So a portion of the band diagram which shows  $E_F$  crossing  $E_d$  is shown here. This is the depletion region, this  $X_n$  is the portion of the depletion layer on the n-side. If you draw the space charge picture it would be something like this;  $q$  into  $N_d$  to the power plus where  $N_d$  to the power plus the ionized impurity concentration. So information as such is revealed by the energy band diagram which is something cannot be obtained without the help of the energy band diagram. Let us summarize how the information given by the five basic equations is reflected in the energy band diagram.

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Let us look at this picture. The fact that  $J_n$  is equal to 0 and  $J_p$  is equal to 0 that is the information from the transport equations is reflected in the fact that the Fermi-level is constant. The Fermi-level is constant with  $x$  so  $E_f$  is constant with  $x$ . This is the information from the transport equation. Next is the fact that there are no excess carriers that is the same  $E_f$  applicable for both electrons and holes so  $E_{fp}$  is equal to  $E_{fn}$  or  $\Delta n$  is equal to  $\Delta p$  equal to 0. This is the information from the continuity equation so the effect of the continuity equation is again shown in the same Fermi-level which is drawn here from the fact that the same Fermi-level is being used for electrons as well as for holes.

What does the Gauss's law say or how information is reflected in this energy band diagram from the Gauss's law? This is reflected in the shape of the  $E_c$ ,  $E_v$  and other levels in the energy gap shape of  $E_c$ ,  $E_v$ ,  $E_d$ ,  $E_a$  and  $E_i$  variations. This is obtained from Gauss's law. For example in this region the  $E_c$  is flat which means there is no electric field here and also there are no space charges where the shapes will be parabolic. So this parabolic shape is again obtained from Gauss's law. These are electronic energies and within this region the shape is parabolic. This is again obtained from the Gauss's law. This is how the information from the five basic equations is clearly reflected in the energy band diagram. So there is a one to one correspondence between various aspects of energy band diagram and the five basic equations.

With this we come to the end of these lectures wherein we considered the equilibrium analysis quantitatively. We solved an example to show the typical values of depletion width, built-in voltage and the peak electric field. Then we also saw how we can draw energy band diagram under equilibrium conditions.